

L Number	Hits	Search Text	DB	Time stamp
201	97	((first or second) near (tft or (thin near film near transistor))) and ((first or second) near (gate near (oxide or insulator or dielectric or insulation)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 20:23
202	45	((first or second) near (tft or (thin near film near transistor))) and ((first or second) near (gate near (oxide or insulator or dielectric or insulation))) and ((first or second) near (gate adj electrode))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 20:24
203	32	((first or second) near (tft or (thin near film near transistor))) and ((first or second) near (gate near (oxide or insulator or dielectric or insulation))) and ((first or second) near (gate adj electrode)) and ((low or high or lightly or highly) near3 (dope or doped or doping or impurity or density) or (ldd or hdd))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 20:36
204	3	((first or second) near (tft or (thin near film near transistor))) and ((first or second) near (gate near (oxide or insulator or dielectric or insulation))) and ((first or second) near (gate adj electrode)) and ((low or high or lightly or highly) near3 (dope or doped or doping or impurity or density) or (ldd or hdd)) and (matsumoto or lee or wakai or seo or yamaguchi)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 20:30
205	13	((first or second) near (tft or (thin near film near transistor))) and ((first or second) near (gate near (oxide or insulator or dielectric or insulation))) and ((first or second) near (gate adj electrode)) and ((low or high or lightly or highly) near3 (dope or doped or doping or impurity or density) or (ldd or hdd)) and (semiconductor adj layer)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 20:47
206	6	((first or second) near (tft or (thin near film near transistor))) and ((first or second) near (gate near (oxide or insulator or dielectric or insulation))) and ((first or second) near (gate adj electrode)) and ((semiconductor near layer) near10 ((low or high or lightly or highly) near3 (dope or doped or doping or impurity or density) or (ldd or hdd))) and (semiconductor adj layer)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 20:40